

Docket No.: 43890-532

PATENT

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Application of :
Toshiaki TAKENAKA, et al. :
Serial No.: 09/928,966 : Group Art Unit: 2836
Filed: August 14, 2001 : Examiner:
For: CIRCUIT BOARD AND METHOD OF MANUFACTURING SAME

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INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
Washington, DC 20231

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

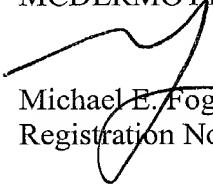
The relevance of each non-English language reference, if any, is discussed in the present specification.

09/928,966

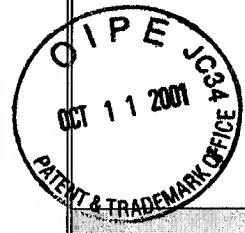
Attached to each non-English reference is an English abstract.

Respectfully submitted,

MCDERMOTT, WILL & EMERY


Michael E. Fogarty
Registration No. 36,139

600 13th Street, N.W.
Washington, DC 20005-3096
(202) 756-8000 MEF:kjw
Date: October 11, 2001
Facsimile: (202) 756-8087



INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(PTO-1449)

ATTY. DOCKET NO.
43890-532

SERIAL NO.
09/928.966

APPLICANT
Toshiaki TAKENAKA, et al.

FILING DATE
August 14, 2001

GROUP
2836

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
	7-106760	04/21/95	JAPAN (w/English Abstract)				X

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER	DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.